## **Chrome Mask Etchant 9030**

Product	Chrome Mask Etchant 9030
Manufacturer	Transene Company, Inc.
Composition	4–6% perchloric acid, 6–8% ceric ammonium nitrate, 86–90% water; liquid
Synonyms	chrome etch
Typical Uses	Wet-etching of chromium thin films (including on photomasks)
Hazards	2 1 0  Specific target organ toxicity – single exposure
Storage	Cabinet 9 (acids cabinet in Wet Aisle 1)
Disposal	Collect in "Chrome etch waste" bottle in Cabinet 9 and dispose of as hazardous material when full.
Comments	
Status	STOCKED



Please contact a nanoFAB staff member for uses not listed above.